

IN THE CLAIMS

Claims 1-17: Canceled.

18. (Currently Amended) A planarization composition, consisting of:
an o-cresol-based polymer compound and a resol phenolic resin;
at least one surfactant; and
a solvent system consisting of at least one solvent.
19. (Previously Presented) The planarization composition of claim 18, wherein the o-cresol-based polymer compound is a novolac polymer.
20. (Currently Amended) The planarization composition of claim 76, wherein the at least one alcohol [[comprises]] is a branched alcohol.
21. (Previously Presented) The planarization composition of claim 20, wherein the branched alcohol is 2-propanol.
22. (Currently Amended) The planarization composition of claim 76, wherein the at least one ether acetate-based solvent [[comprises]] is propylene glycol methylether acetate (PGMEA).
23. Canceled.
24. (Currently Amended) The planarization composition of claim 18, wherein the surfactant [[comprises]] consists of at least one non-fluorinated surfactant, at least one fluorocarbon-based surfactant or a combination thereof.
25. (Currently Amended) The planarization composition of claim 24, wherein the at least one fluorocarbon-based surfactant [[comprises]] consists of at least one fluoroaliphatic polymeric ester surfactant.
26. (Previously Presented) A film comprising the planarization composition of claim 18, wherein at least some of the solvent system is removed.

27. (Previously Presented) A film comprising the planarization composition of claim 24, wherein at least some of the solvent system is removed.

Claims 28-29: Canceled.

30. (Original) A layered component, comprising:
a substrate having a surface topography; and
a planarization composition of claim 18, wherein the composition is coupled to the substrate.
31. (Original) The layered component of claim 30, further comprising at least one additional layer of material or film.
32. (Original) A layered component, comprising:
a substrate having a surface topography; and
a layer comprising the film of claim 26, wherein the layer is coupled to the substrate.
33. (Original) The layered component of claim 32, further comprising at least one additional layer of material or film.
34. (Original) A layered component, comprising:
a substrate having a surface topography; and
a layer comprising the film of claim 27, wherein the layer is coupled to the substrate.
35. (Original) The layered component of claim 34, further comprising at least one additional layer of material or film.
36. (Currently Amended) A method of forming a planarization composition, consisting of:

providing an o-cresol-based polymer compound and a resol phenolic resin as a structural constituent;

providing at least one surfactant;

providing a solvent system consisting of at least one solvent; and

blending the structural constituent, the at least one surfactant and the solvent system to form a planarization composition.

Claims 37-40: Canceled.

41. (Previously Presented) The method of claim 77, wherein the alcohol-based solvent is 1-propanol or 2-propanol.
42. (Currently Amended) The method of claim 36, wherein the solvent system [[comprises]] consists of propylene glycol methyl ether acetate (PGMEA), ethyl lactate, propylene glycol methyl ether, diethylene glycol, 2-propanol, acetone or a combination thereof.

Claims 43-46: Canceled.

47. (Original) The method of claim 36, wherein the planarization composition comprises an apparent viscosity.
48. (Previously Presented) The method of claim 47, wherein the solvent system lowers the apparent viscosity by at least 10%.
49. (Original) The method of claim 48, wherein the solvent system lowers the apparent viscosity by at least 30%.
50. Canceled.
51. (Currently Amended) The method of claim 36, wherein the surfactant [[comprises]] consists of at least one non-fluorinated surfactant, at least one fluorocarbon-based surfactant or a combination thereof.
52. (Currently Amended) The method of claim 51, wherein the at least one fluorocarbon-based surfactant [[comprises]] consists of at least one fluoroaliphatic polymeric ester surfactant.
53. (Previously Presented) A method of forming a film, comprising:

providing the planarization composition of claim 18; and
evaporating at least part of the solvent system to form a film.

- 54. (Original) The method of claim 53, wherein evaporating at least part of the solvent system comprises applying a continuous source to the planarization composition.
- 55. (Original) The method of claim 54, wherein the continuous source comprises a heat source.
- 56. (Original) The method of claim 55, wherein the continuous source comprises an infrared source, an ultraviolet source, an electron-beam source and combinations thereof.

Claims 57-75: Canceled.

- 76. (Previously Presented) The planarization composition of claim 18, wherein the solvent system consists of at least one alcohol and at least one ether acetate-based solvent.
- 77. (Previously Presented) The method of claim 36, wherein the solvent system consists of at least one alcohol and at least one ether acetate-based solvent.